

XP-002202905

AN - 1998-529583 [45]
AP - RU19960118887 19960930
CPY - KHIM-R
- ZASC-R
DC - A26 A97 C01 P11
FS - CPI;GMPI
IC - A01C1/06
IN - FILIPPOVA S M; ISHMURATOV A S; SAVELEV N I
MC - A06-A00E1 A12-W04B C04-C03D C05-B01B C14-U02
M1 - [01] B414 B713 B720 B798 B832 H4 H401 H402 H481 H482 H5 H581 H583 H8
L660 L699 M210 M211 M212 M213 M214 M215 M216 M231 M232 M233 M272 M282
M283 M311 M312 M313 M314 M315 M322 M323 M331 M332 M333 M340 M342 M383
M392 M393 M411 M423 M510 M520 M530 M540 M620 M781 M903 M904 P130 Q110
V743; 9841-HMT01-U
PA - (KHIM-R) KHIMPTOM STOCK CO
- (ZASC-R) ZASHCHITA RASTENII CO LTD
PN - RU2104626 C1 19980220 DW199845 A01C1/06 004pp
PR - RU19960118887 19960930
XA - C1998-158799
XIC - A01C-001/06
XP - N1998-413110
AB - RU2104626 Composition for the treatment of seeds comprises: (a)
oligomeric polyalkoxysiloxane of formula (I):
 $\text{HO}((\text{RO})_2\text{SiO}-\text{Si}(\text{OH})(\text{OR})-\text{OSi}(\text{OR})(\text{OR}'))_n\text{OH}$ (I) where R is 2-4C alkyl, R'
is 2-4C alkyl or $(\text{CH}_2-\text{CH}_2\text{O})_9\text{OH}$ and $n = 4-25$, as a film-forming
component, in amounts of not less than 0.02 kg/10 l of the working
suspension used in the treatment of seeds; (b) non-ionogenic
surfactant; (c) dye; and (d) seed dressing material.
- ADVANTAGE - The mixture is more easily homogenised in water.
- (Dwg.0/0)
CN - 9841-HMT01-U
IW - COMPOSITION TREAT SEED CONTAIN NON IONOGENIC SURFACTANT DYE SEED DRESS
POLY ALKOXY SILOXANE FILM FORMING COMPONENT
IKW - COMPOSITION TREAT SEED CONTAIN NON IONOGENIC SURFACTANT DYE SEED DRESS
POLY ALKOXY SILOXANE FILM FORMING COMPONENT
INW - FILIPPOVA S M; ISHMURATOV A S; SAVELEV N I
NC - 001
OPD - 1996-09-30
ORD - 1998-02-20
PAW - (KHIM-R) KHIMPTOM STOCK CO
- (ZASC-R) ZASHCHITA RASTENII CO LTD
TI - Composition for the treatment of seeds - contains non-ionogenic
surfactant, dye, seed dressing, and poly:alkoxy-siloxane as
film-forming component
A01 - [001] 018 ; D50 D90 D91 D92 D93 D94 D95 F81 F84 F87 ; D82 ; P1445-R
F81 Si 4A ; H0260 ; S9999 S1014-R ; P0975-R P0964 F34 D01 D10 ;
H0237-R ;
- [002] 018 ; D50 D90 D91 D92 D93 D94 F81 F84 F86 F87 ; P1445-R F81 Si
4A ; S9999 S1014-R ;
- [003] 018 ; ND01 ; Q9999 Q6768 Q6702 ;